Supporting Information

A highly colorimetric and ratiometric fluorescent probe for fluoride ion and fluoride ion test-strip

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1. The photostability of NP-OTBDPS.

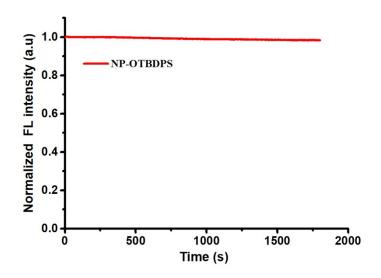
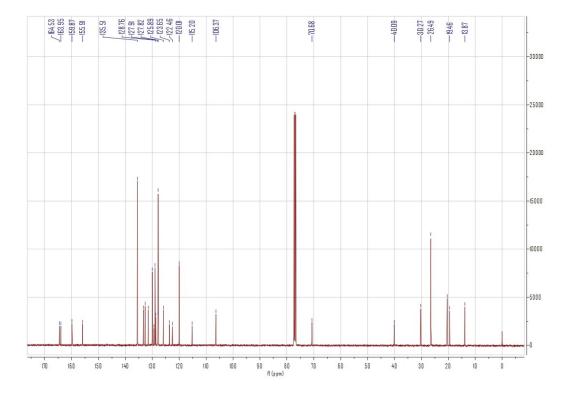


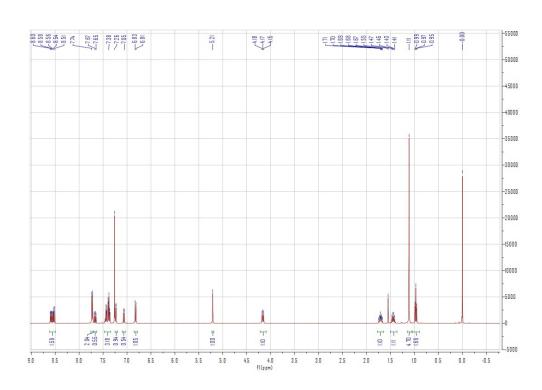
Fig.S1. The photostability of the probe (5 μ M) detected in PBS-DMSO.(v/v = 1/9, pH=7.4, PBS=10 mM). $\lambda ex = 300$ nm, Slit width: 5 nm/5 nm.

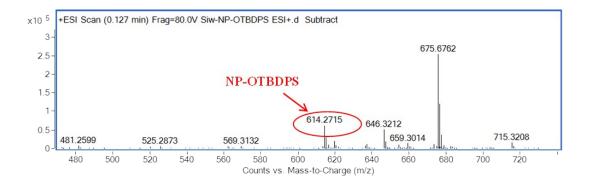
2. The characterization data of NP-OTBDPS.



NP-OTBDPS ¹³C NMR

NP-OTBDPS ¹H NMR





ESI- MS spectrum of NP-OTBDPS